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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/710,698	07/29/2004	Tai-Yuan Chen	12739-US-PA	4697	
	7590 05/26/200 N INTELLECTUAL PI	EXAMINER			
7 FLOOR-1, NO. 100 ROOSEVELT ROAD, SECTION 2 TAIPEI, 100			SALZMAN, KOURTNEY R		
			ART UNIT	PAPER NUMBER	
TAIWAN			1795		
			NOTIFICATION DATE	DELIVERY MODE	
			05/26/2009	ELECTRONIC	

# Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

USA@JCIPGROUP.COM.TW Belinda@JCIPGROUP.COM.TW

		Applic	Application No. Applicant(s)				
		10/71	0,698	CHEN ET AL.			
Office Action Summary			ner	Art Unit			
			TNEY R. SALZMAN	1795			
Period fo	The MAILING DATE of this communic or Reply	ation appears on	the cover sheet with the	e correspondence a	ddress		
A SH WHIC - Exter after - If NC - Failu Any I	ORTENED STATUTORY PERIOD FOR CHEVER IS LONGER, FROM THE MA assions of time may be available under the provisions of SIX (6) MONTHS from the mailing date of this commure of period for reply is specified above, the maximum statue to reply within the set or extended period for reply withi	ILING DATE OF 37 CFR 1.136(a). In n ication. tory period will apply a I, by statute, cause the	THIS COMMUNICATION OF EVENT, however, may a reply be not will expire SIX (6) MONTHS for application to become ABANDO	ON. timely filed om the mailing date of this NED (35 U.S.C. § 133).			
Status							
'	Responsive to communication(s) filed This action is <b>FINAL</b> . 2b Since this application is in condition fo closed in accordance with the practice	) This action rallowance exc	is non-final. ept for formal matters, p		ne merits is		
Dispositi	on of Claims						
5)□ 6)⊠ 7)□ 8)□ <b>Applicat</b> i	Claim(s) <u>8-15</u> is/are pending in the applea of the above claim(s) is/are Claim(s) is/are allowed.  Claim(s) <u>8-15</u> is/are rejected.  Claim(s) is/are objected to.  Claim(s) are subject to restriction on Papers  The specification is objected to by the lateral or and the drawing(s) filed on is/are: a subject to restrict on the drawing(s) filed on is/are: a subject of the lateral or and the drawing(s) filed on is/are: a subject of the lateral or and the drawing sheet(s) including the subject of the lateral or and the subject of the su	withdrawn from on and/or election and/or election examiner.  a) accepted on to the drawing(	n requirement. r b)  objected to by the s) be held in abeyance. S	See 37 CFR 1.85(a).	CFR 1.121(d).		
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority ι	ınder 35 U.S.C. § 119						
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>							
2)  Notic 3)  Inform	t(s) e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PT0 mation Disclosure Statement(s) (PTO/SB/08) r No(s)/Mail Date	D-948)	4) Interview Summa Paper No(s)/Mail 5) Notice of Informa 6) Other:	Date			

Application/Control Number: 10/710,698 Page 2

Art Unit: 1795

#### **DETAILED ACTION**

### Summary

- 1. The amendment filed March 10, 2009 has been entered and fully considered.
- 2. Claim 13 has been amended.
- 3. Claims 8-15 are currently pending and have been fully considered.

## Claim Rejections - 35 USC § 103

- 4. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.
- 5. Claims 8-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over BRAEUER et al (US 5,164,063) and YOKOYAMA et al (JP 62-089864, abstract).

Regarding claims 8 and 13, BRAEUER et al teaches a sputtering cathode featuring a magnetron comprising two magnet arrangements as shown in figure

3. A reaction chamber is shown to be present in figure 1 above the target substrate at the bottom of the figure. Reference number 9 and 9' represent the first set of magnets, while reference numbers 10 and 10' represent the second set. These magnets are shown planarly and axially symmetric to each other. The magnets adjacent to each other within the sets or 9 and 9' or 10 and 10' have opposite poles as shown by the N and S designations on the figure respectively. BRAEUER et al teaches in column 3, lines 23-26, that the polarity of the magnet sets is only selected in order to form the plasma ring, but does not restrict the magnet polarities to those shown in figure 3.

Art Unit: 1795

BRAEUER et al does not show the magnets symmetric to each other having opposite orientations.

YOKOYAMA et al teaches a magnetron sputtering device comprising magnets whose poles can be either N or S, neither is required for efficiency.

At the time of invention, it would have been obvious to try any combination of polarities of the magnet sets together. There are only 4 combinations of polarities which create the plasma of BRAEUER et al where the magnets within the sets have different polarities. Therefore, it would have been obvious to manipulate the magnet sets of BRAEUER et al, by utilizing either polarity interchangeably as shown in YOKOYAMA et al, without undue experimentation, and still yield the predictable result of creating the plasma rings of BRAEUER et al.

Regarding the final limitation of claim 13, it is obvious to begin magnetron rotation before deposition begins and end rotation after deposition is complete, as this is the normal order of the process steps in a magnetron system. Since the magnet sets are not symmetric in their polarity it is clear their deposition would not be symmetric as well. However, since there is rotation the asymmetrical magnets sets will work to together to produce a symmetrical deposition surface.

Art Unit: 1795

Regarding claim 9, in conjunction with the previous rejection of claim 8,
BRAEUER et al teaches a chamber shown in figure 1, with a target holding pot
14 as the target backboard, shown at the top of the chamber. At the bottom of
the chamber, piece F is shown to function as the platen.

Regarding claim 10, in conjunction with the previous rejection of claim 9, the central axis of BRAEUER et al is shown in figure 1 to be M and is stated in the abstract to run through the center of the target, and therefore the backboard.

Regarding claim 11, in conjunction with the previous rejection of claim 8, BRAEUER et al shows in figure 3, the first magnet to be any magnet of group 10 and the second magnet to be of group 10'. The third magnet is the axially symmetric counterpart to the first magnet in group 9 and the fourth is the axially symmetric counterpart to the second magnet in group 9'. The first magnet has a pole of N and the fourth magnet has a pole of S. The second magnet has a pole of S and the third magnet has a pole of N.

Regarding claim 12, in conjunction with the previous rejection of claim 8,

BRAEUER et al shows in figure 3, the first magnet to be any magnet of group 10

and the second magnet to be of group 10'. The third magnet is the planarly

symmetric counterpart to the first magnet in group 9, where the plane is the

Application/Control Number: 10/710,698 Page 5

Art Unit: 1795

horizontal plane through center portion M of the yoke. The fourth is the planarly symmetric counterpart to the second magnet in group 9'. The first magnet has a pole of N and the fourth magnet has a pole of S. The second magnet has a pole of S and the third magnet has a pole of N.

Regarding claims 14 and 15, in conjunction with the previous rejection of claim 13, it would be obvious to one of ordinary skill in the art for a rotating magnetron or rotating yoke plate to at least rotate 180n or 360n during the process of deposition and in most cases many more rotations.

### Response to Arguments

- 6. Applicant's arguments filed March 10, 2009 have been fully considered but they are not persuasive.
- 7. Applicant argues on page 8 that neither BRAEUER or YOKOYAMA teach the "two symmetrical magnets in two correspondingly symmetrical magnet sets have opposite orientations in magnetic pole" and that by changing the polarities of the magnets of BRAEUER, the reference is destroyed.
  - a. BRAEUER and YOKOYAMA both show that the polarities are interchangeable. YOKOYAMA discusses in the abstract that the polarities can be interchangable as either an N or S pole is available for use. BRAEUER also teaches that the magnets sets should be of opposite polarities, but does not require either polarity explicitly in claim 3, listed in column 4, lines 37-40. Since no polarity is specified it becomes a matter of engineering choice. Applicant

Application/Control Number: 10/710,698

Art Unit: 1795

states that the goal of BRAEUER is to create a uniform erosion profile and while the profile is shown, the goal is not the profile, but the result of the chosen magnet layout, as stated in column 3, lines 39-47, to sputter coat the surface. The sputtered surface of the substrate is the goal of the invention of BRAEUER as the invention and is continually taught to be used for coating, not for the uniform target erosion, in the abstract and column 1, lines 6-15 for example. Clearly, it would have been obvious to manipulate the magnets polarities as stated in claim 3 or column 4, lines 37-40 provided a coating on the sputtered surface can be achieved.

Page 6

#### Conclusion

8. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to KOURTNEY R. SALZMAN whose telephone number is

Art Unit: 1795

(571)270-5117. The examiner can normally be reached on Monday to Thursday 6:30AM-5PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam Nguyen can be reached on (571) 272-1342. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Kaj K Olsen/ Primary Examiner, Art Unit 1795

krs 5/19/2009